

PULSED RESPONSE OF HIGH-SPEED SEMICONDUCTOR LASER (InGaAsP)

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ABSTRACT

Digital response of high-speed semiconductor lasers has been modelled and investigated under different thermal conditions and no parasitic bonding pads. The widest digital modulation of InGaAsP diode lasers has been analyzed on the base of small amplitude model. Both the optical gain and the carrier concentration at transparency are correlated as temperature-dependent parameters of exponential forms. Three relevant items of major interest are studied to account for the thermal digital modulation of the optical device: i) the steady state response; its ultimate value, and the ratio between them ii) the 3-dB of the ratio above, and iii) the steady state harmonic response. The problem has been investigated under wide ranges of two major affecting parameters: the injected current and the device temperature.

1. INTRODUCTION

The field of high-speed semiconductor lasers has undergone substantial advances since the first demonstration of a laser with a modulation bandwidth beyond 10 GHz [1,2]. Such device are of great importance for optical communication systems due to their small size, high efficiency, easy handling and controllability, and high speed for direct modulation which has been a subject of special emphasis and active research for the past 30 years.

There are three important factors to be considered to realize high-speed long-span transmission systems [3]: i) high frequency response of laser diodes, APD's and electrical circuits, ii) spectral characteristics of LD output, when directly modulated with high speed pulse streams, and iii) optical fiber dispersion and transmission loss characteristics.

Wide bandwidth transmission systems today utilize directly modulated In GaAsP laser with spectral linewidths of about 4nm, and In GaAs p-i-n or Ge-APD photodiodes [4].

By reducing active layer with of constricted-mesa lasers to 1 μ m, CW bandwidth has been increased to 16 GHz at 20°C and to 26.5 GHz at -60°C. The pulsed 20°C bandwidth was 22 GHz [5]. These mentioned data indicated that the present bandwidth limitation is predominantly thermal. A best-ever 22 GHz CW 3dB bandwidth was reported in Ref. [6] for a 1.3 μ m InGaAsP vapour-phase-regrown buried heterostructure laser. The device was shown to have excellent modulation efficiency.

The differential gain of 1.3 μ m InGaAsP lasers was found to be a strong function of the active layer doping level [7]. A modulation bandwidth of 15 GHz was achieved, using devices with doping enhanced differential gain and short cavity lengths. To avoid the large wavelength chirping that accure in a high-speed direct modulation, which severely limits the span-rate system product, the external modulation technique was employed [8], where a high frequency response (\approx 7 GHz) was measured with a small linewidth enhancement factor.

The modulation characteristics of InGaAsP laser diodes grown on p-type substrate have been studied experimentaly [9], on devices in which the parasitic bonding pads have been eliminated.

A small signal 3-dB bandwidth as high as 16.4 GHz has been measured. Also, the laser has responded to large-signal digital sequences at rates of 16 G bit/sec.

The dynamic behavior of 1.3 μ m InGaAsP p-substrate buried crescent (PBC) lasers emitting maximum output powers of more than 30 m Watt//facet was characterized in detail [10] where a 3-dB modulation bandwidth of 11.5 GHz was observed.

To the best of our knowledge, no theoretical study for the thermal dependence of the physical parameters and its effect on the modulation bandwidth had been considered, thus in the present paper, and on the bases of the rate equations for a single-mode semiconductor laser

(InGaAsP) with uniform carrier distribution, the thermal dependent digital modulation bandwidth is modelled, analyzed, and investigated over wide range of the controlling parameters of such optical devices.

II. Basic Model and Thermal Analysis:

To examine the thermal-dependent digital modulation characteristics, consider the rate equations for single-mode semiconductor laser with uniform carrier distributions [11].

$$\frac{dN}{dt} = \frac{I}{qV} - g'(N - N_T)S - \frac{N}{\tau_n} \tag{1}$$

$$\frac{dS}{dt} = g'(N - N_T)S - \frac{S}{\tau_p} + \frac{B \Gamma N}{\tau_n} \tag{2}$$

where N and S are the electron and photon densities in the active layer, m⁻³, I is the device current, q is the electron charge, V is the active layer volume, g' is the differential gain, N_T is the electron concentration at transparency, τ_n and τ_p are electron and photon lifetimes, B is the fraction of spontaneous emission coupled into the lasing mode, and Γ is the mode confinement factor. Based on microwave and millimeter wave measurements the expression for gain saturation in a two-level system is taken as in [12].

$$g' = g_o / (1 + \epsilon S) \tag{3}$$

Where ε is small parameter and ε S << 1.
For small-signal

$$S = S_o + s e^{j\omega t}$$

$$N = N_o + n e^{j\omega t}$$

$$I = I_o + i e^{j\omega t}$$

The frequency response of a laser without parasitic [11] is

$$G(j\omega) = \frac{1}{i} = \frac{A}{\omega^2 + jB\omega + C} \tag{4}$$

where A, B, and G are real

$$A = \frac{-1}{qV} \left(\frac{\Gamma g_o S_o}{1 + \epsilon S_o} + \frac{\Gamma B}{\tau_n} \right)$$

$$B = \frac{-g_o S_o}{1 + \epsilon S_o} - \frac{1}{\tau_n} \frac{\Gamma g_o (N_o - N_T)}{1 + \epsilon S_o} - \frac{1}{\tau_p}$$

$$C = \left(\frac{g_o S_o}{1 + \epsilon S_o} + \frac{1}{\tau_n} \right) \left(\frac{\Gamma g_o (N_o - N_T)}{1 + \epsilon S_o} - \frac{1}{\tau_p} \right) - \frac{g_o (N_o - N_T)}{1 + \epsilon S_o} \left(\frac{\Gamma g_o S_o}{1 + \epsilon S_o} + \frac{\Gamma B}{\tau_n} \right)$$

The pulse transfer function G(z) for discrete analysis obtained as follows steps.

- a- derivation of the corresponding transfer function using Laplace transform G(s).
- b- finding the weighting function g(t)
- c- finding the z-transform of the weighting function (z).

Thus, the pulse transfer function G(z) is derived from Eq. (4) employing the above mentioned procedure as:

$$G(s) = \frac{S(s)}{I(s)} = - \frac{A}{s^2 B s - C}$$

then

$$g(t) = A_o \exp\left(\frac{B}{2}t\right) \sin \omega_o t$$

where

$$\omega_o = \sqrt{(B^2/4) - C}$$

$$A_o = - A/\omega_o$$

and finally

$$G(z) = \frac{S(z)}{I(z)} = A_o \frac{zD}{z^2 - zE + F}$$

where

$$D = e^{BT_s/2} \sin \omega_0 T_s$$

$$E = 2 \cos \omega_0 T_s e^{BT_s/2}$$

$$F = e^{BT_s}, \text{ and}$$

T_s is the sampling interval

It is known [13] that the sampled input signal applied to the continuous plant in a sampled data system can be treated as consisting of a series of impulses approximating the finite duration pulses which arise in the actual sampling process. The weigh of each impulse is equal to $T_s y(kT_s)$ where $y(kT_s)$ is the value of the input signal at sampling time $t = kT_s$. Using the inpulse approximation of the sample input signal, it can be shown that the unit step z-transform is given by

$$I(z) = \frac{T_s z}{z-1} \quad (8)$$

The use of Eq. (8) into Eq. (7) yields

$$S(z) = \frac{T_s z}{z-1} \cdot G(z) \quad (9)$$

Taking the inverse z-transform, the discrete output signal

$$S(kT_s) = R_1 + R_2 + R_3 \quad (10)$$

where

$$R_1 = \lim_{z \rightarrow 1} (z-1)S(z)z^{k-1} = A_0 T_s D \cdot \frac{1}{1-E+F}, \quad (11)$$

$$R_2 = \lim_{z \rightarrow 1} (z-1)S(z)z^{k-1} = A_0 T_s D \cdot \frac{z_1^{k-1}}{(z_1-1)(z_1-z_2)}, \text{ and} \quad (12)$$

$$R_3 = \lim_{z \rightarrow 2} (z-z_2)S(z)z^{k-1} = A_0 T_s D \cdot \frac{z_2^{k-1}}{(z_2-1)(z_2-z_1)} \quad (13)$$

where

$$z_{1,2} = \frac{1}{2}(E \pm \sqrt{E^2 - 4F}) \text{ are the roots of: } z^2 + Fz + F = 0.0$$

Starting from Eq. (7), the steady state response of a discrete time system [14] is

$$H(e^{j\omega t}) = A_0 D T_s \frac{e^{j\omega t}}{e^{2j\omega t} - E e^{j\omega t} + F} \quad (14)$$

The amplitude response of this function is derived as:

$$A(\omega t) = \sqrt{H(e^{j\omega t})H(e^{-j\omega t})} \\ = A_0 T_s D \left[\sqrt{1 + E^2 + F^2 - 2E(1+F)\cos \omega t + \sqrt{2F\cos 2\omega t}} \right]^{-1} \quad (15)$$

The normalized amplitude response $A_n(\omega t)$ is given as

$$A_n = A(\omega t)/A(0) \\ = \frac{1-E+F}{\sqrt{1 + E^2 + F^2 - 2E(1+F)\cos \omega t + 2\cos 2\omega t}} \quad (16)$$

Assuming that the overshoot, M , is required to be at $\omega_M T_s < \tau$, and taking into account that the cut-off occurs at $\omega_c T_s = \omega$ [13,14], we design the following criterion to calculate the maximum bandwidth at the overshoot i.e., $\omega_M = \omega_c$

$$\text{i.e. } \cos \omega_M T_s = -1$$

$$\text{or } E(1+F) + 4F = 0.0$$

$$E + F(4+E) = 0.0 \quad (17)$$

Equation (17) yields the smallest sampling interval. The approximate solution of Eq. (17) gives

$$BT_{\min} \approx -1.5 \quad (18)$$

Thus, the highest sampling frequency is given as

$$f_{\max} = \frac{1}{T_{\min}} \approx \frac{1}{3} B \quad (19)$$

Another approach to study the effect of the sampling interval is the steady state step response which is given as

$$S(\infty) = \lim_{z \rightarrow 1} \frac{z-1}{z} S(z) \quad (20)$$

The use of Eq. (7) and Eq. (9) into Eq. (20) gives

$$\begin{aligned} S_{T_s}(\infty) &= \lim_{z \rightarrow 1} A_0 T_s D \frac{z}{z^2 - Ez + F} \\ &= A_0 T_s D \cdot \frac{1}{1 - E + F} \end{aligned} \quad (21)$$

$S(\infty)$ possesses an ultimate value, $S_u(\infty)$, when T approaches a zero value where

$$S_u(\infty) = \lim_{T_s \rightarrow 0} S(\infty) = - \frac{A}{(B^2/2) - C} \quad (22)$$

which has a mathematical meaning only. A quantity of special interest is the ratio:

$$R(T_s) = \frac{S_{T_s}(\infty)}{S_u(\infty)} = \frac{(B^2/2) - C}{\sqrt{(B^2/4) - C}} T_s D \frac{1}{1 - E + F} \quad (23)$$

A physical quantity of important interest is the sampling interval, T_{3dB} , corresponding to 3-dB point of $R(T_s)$ i.e. T_{3dB} is the solution of

$$10 \log R_0 \cdot \frac{T_s D}{1 - E + F} = -3$$

or

$$R_0 \frac{T D}{1 - E + F} = \frac{1}{2} \quad (24)$$

where

$$R_0 = \frac{(B^2/2) - C}{\sqrt{(B^2/4) - C}}$$

RESULTS AND DISCUSSION

The advances in high speed semiconductor laser

technology described in recent articles [1-12] have opened up new areas of applications involving high-data-rate high speed analog and microwave transmission through optical fibers.

In general, the three fundamental parameters that govern the modulation bandwidth of injection laser are the photon density, the injected current, and the optical gain.

Both the optical gain g_0 and the threshold electron density N_T are temperature-dependent relevant physical parameters. Based on the data published in Ref. [15] and on the same spirit of Refs [16-19], the following temperature-dependent correlations have been derived for both g_0 and N_T where:

$$g_0(T) = g_0(300) \exp[-4.5(T-300)/300] \quad (25)$$

and

$$N_T(T) = N_T(300) \exp[2.4(T-300)/300] \quad (26)$$

Taking Eqs. (25) and (26) into consideration in the present paper, three relevant topics are studied in detail namely:

- i- Steady state step response $S_{T_s}(\infty)$ and its ultimate values, $S_u(\infty)$.
- ii- The ratio of $S_{T_s}(\infty)/S_u(\infty)$.
- iii- The 3-dB point of the ratio above.
- iv- The steady state harmonic response of the device.

The above items are considered for the device under digital modulation.

The frequency (bit-rate) at which the ratio $S_{T_s}(\infty)/S_u(\infty)$ reaches to 3-dB and denoted as f_{3dB} displayed in Figures (1) and (2) where it is clear that:

- i- f_{3dB} possesses a monotonic variation
- ii- as the device is cooled, f_{3dB} increases.
- iii- as the injection current increases, f_{3dB} also increases.

A simple quadratic relation is tailored, using curve fitting technique, under the form

$$f_{3dB} = f_0 + f_1 I + f_2 I^2, \text{ GHz} \quad (27)$$

where f_0 , f_1 , and f_2 are expressed as

$$f_0 = 24.197 - 0.054324 T - 8.8201 \times 10^{-5} T^2 \quad (28)$$

$$f_1 = 1514.4 - 8.2318 T + 0.013446 T^2 \quad (29)$$

$$f_2 = -4092.0 + 23.646 T - 0.041804 T^2 \quad (30)$$

I is in amperes and T is in $^{\circ}\text{K}$.

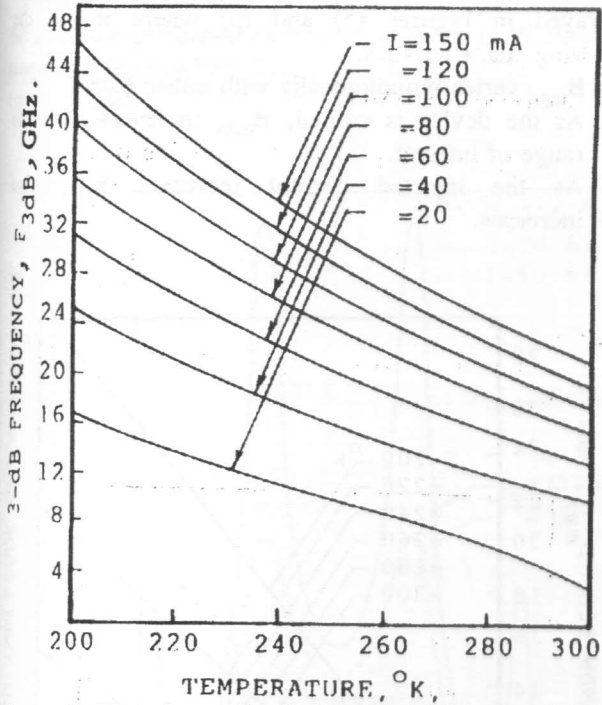


Figure 1. Variation of 3-dB frequency, f_{3dB} , against the variations of temperature, T , for different injected current, I .

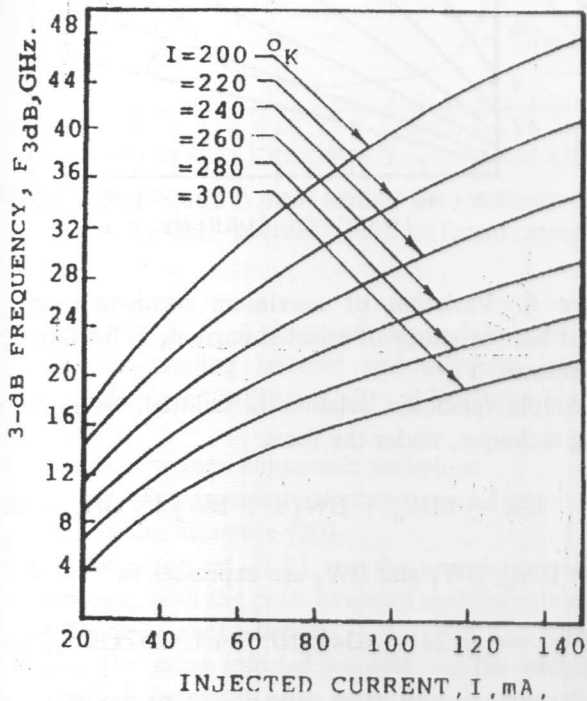


Figure 2. Variation of 3-dB frequency, f_{3dB} , against the variations of injected current, I , for different temperature, T .

The sampling interval corresponding to 3-dB bandwidth, T_{3dB} , is clarified in Figures (3) and (4) where T_{3dB} possesses the following characteristics:-

- i- T_{3dB} possesses a monotonic variation,
- ii- As the device is cooled, T_{3dB} decreases.
- iii- As the injection current increases, T_{3dB} decreases.

A simple quadratic relation is tailored, using curve fitting technique, under the form

$$T_{3dB} = T_0 + T_1 I + T_2 I^2, \text{ n sec.} \quad (31)$$

where T_0 , T_1 , and T_2 are expresses as:

$$T_0 = 1.3751 - 0.012194 T + 2.85517 \times 10^{-5} T^2 \quad (32)$$

$$T_1 = -27.932 + 0.24809 T + 5.6547 \times 10^{-4} T^2$$

$$T_2 = 133.62 - 1.8677 T + 2.6896 \times 10^{-3} T^2 \quad (33)$$

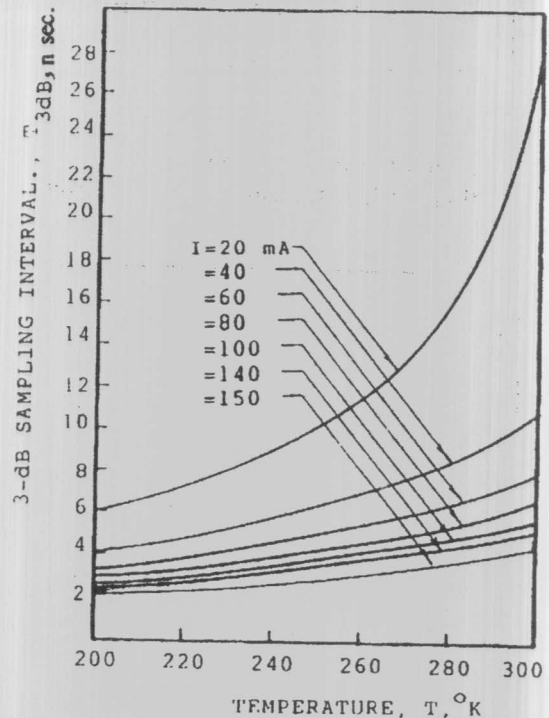


Figure 3. Variation of 3-dB sampling interval, T_{3dB} , against the variations of temperature, T , for different injected current, I .

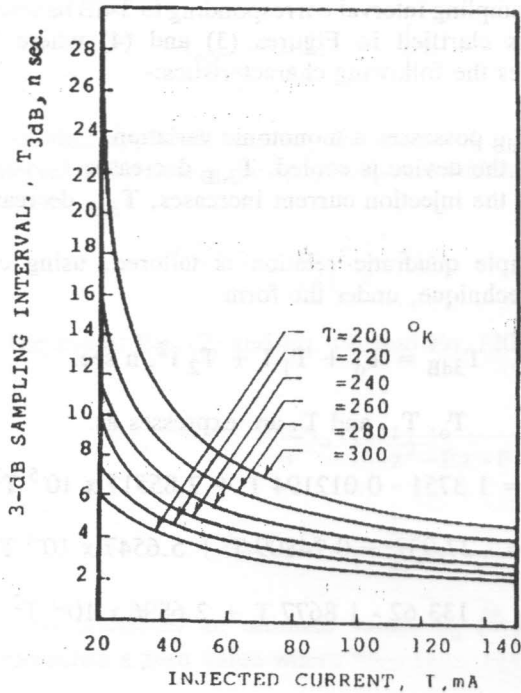


Figure 4. Variation of 3-dB sampling interval, T_{3dB} , against the variations of injected current, I , for different temperature, T .

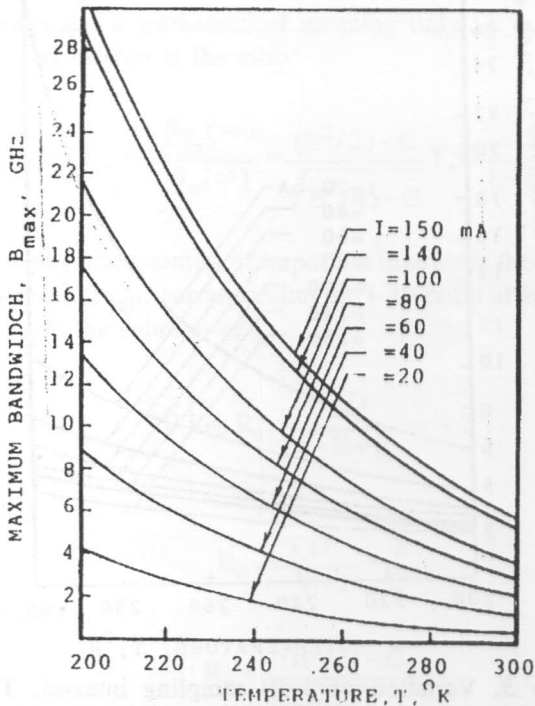


Figure 5. Variation of maximum bandwidth, B_{max} , against the variations of temperature, T , for different injected current, I .

The maximum bandwidth for digital processing B_{max} is portrayed in Figures (5) and (6) where it has the following characteristics:

- i- B_{max} varies monotonically with either I or T
- ii- As the device is cooled, B_{max} increases over the range of interest.
- iii- As the injected current increases B_{max} also increases.

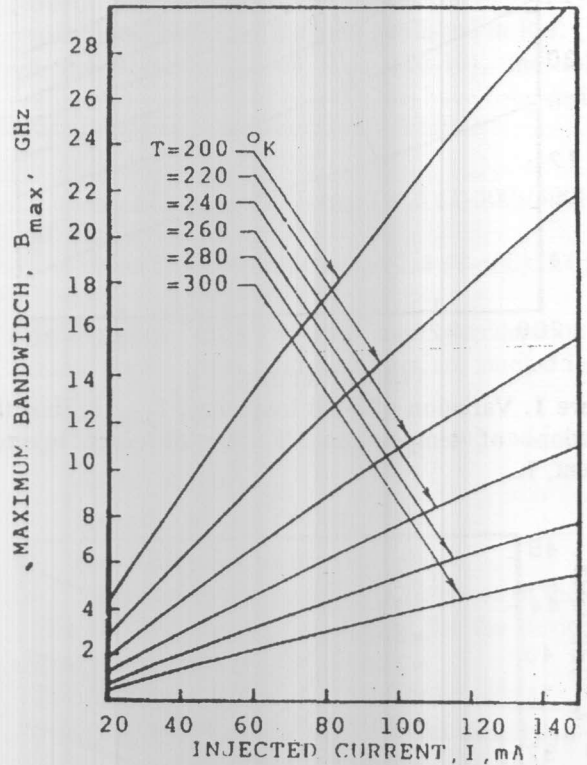


Figure 6. Variation of maximum bandwidth, B_{max} , against the variations of injected current, I , for different temperature, T .

A simple quadratic relation is tailored, using curve fitting technique, under the form

$$BW = MW_0 + BW_1 I + BW_2 I^2, \text{ GHz} \quad (35)$$

where BW_0 , BW_1 and BW_2 are expressed as

$$BW_0 = -0.61241 - 3.6349 \times 10^{-3} T + 1.4257 \times 10^{-5} T^2 \quad (36)$$

$$BW_1 = 1607.4 - 9.9697 T + 0.01590 T^2 \quad (37)$$

$$BW_2 = -1907.4 + 11.248 T + 0.0187 T^2 \quad (38)$$

The above characteristics are in good agreement with the available published experimental work [6,9] over the range of interest where $200 \leq T (^{\circ}\text{k}) \leq 300$ and $20 \leq I (\text{mA}) \leq 150$.

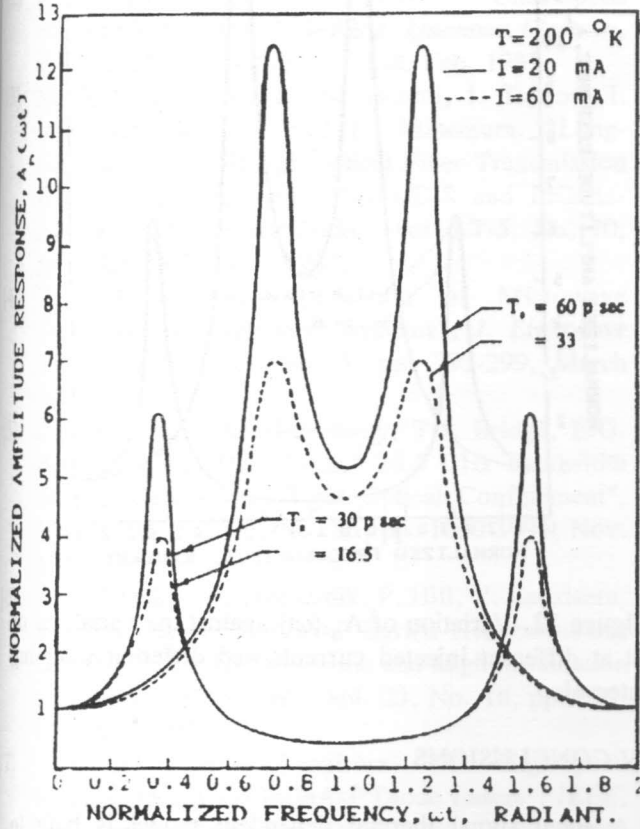


Figure 7. Variation of $A_n(\omega t)$ against the variations of ωt at different injected currents and different sampling intervals.

The variations of $A_n(\omega t)$ against the variations of ωt at different sampling interval and different injected current are displayed in Figures (7) - (12). These Figures clarify that

- i- $A_n(\omega t)$ possesses monotonic variations
- ii- $A_n(\omega t)$ has a symmetrical shape around $\omega t = \pi$ as given in the literature [20].
- iii- For the same set $\{I, T\}$, as the sampling interval increases, both the peak overshoot and the minimum values of $A_n(\omega t)$ increase.
- iv- For the same injected current, as the sampling interval increases, the peak of the normalized amplitude response increases and shift to the higher normalized frequency.

- v- As the injected current increase, the overall response shrinks but the maximum value and the minimum are at the same frequencies.
- vi- For the same injected current, as the temperature increases, the 3-dB time interval T_{3dB} increases which in turns means the reduction of capacity of in for motion transmission. Such situation gives the tendency to cool the optical transmitter.

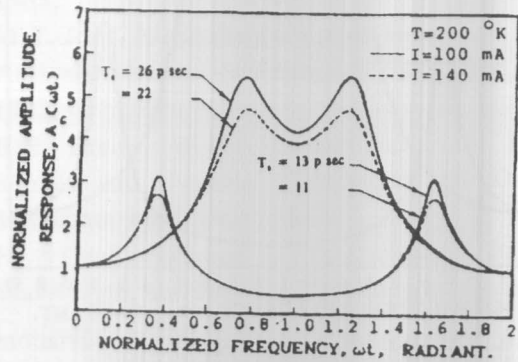


Figure 8. Variation of $A_n(\omega t)$ against the variations of ωt at different injected currents and different sampling intervals.

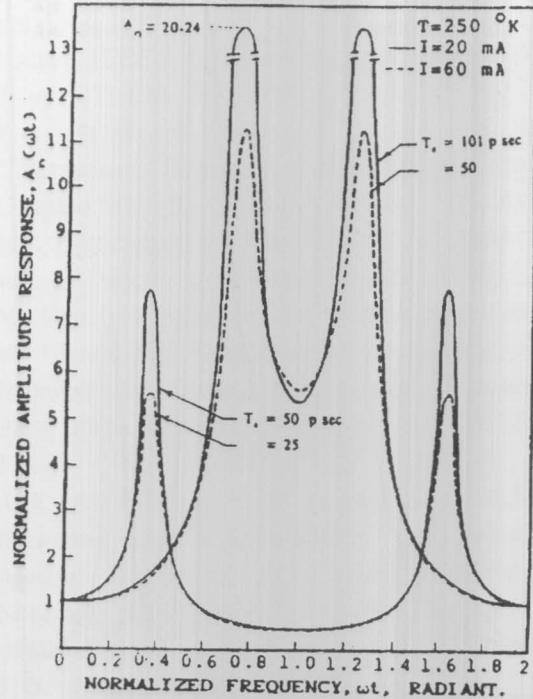


Figure 9. Variation of $A_n(\omega t)$ against the variations of ωt at different injected currents and different sampling intervals.

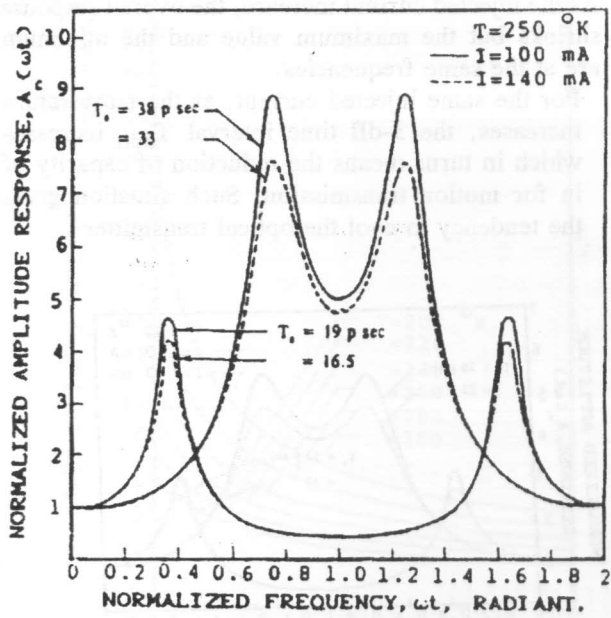


Figure 10. Variation of $A_n(\omega t)$ against the variations of ωt at different injected currents and different sampling intervals.

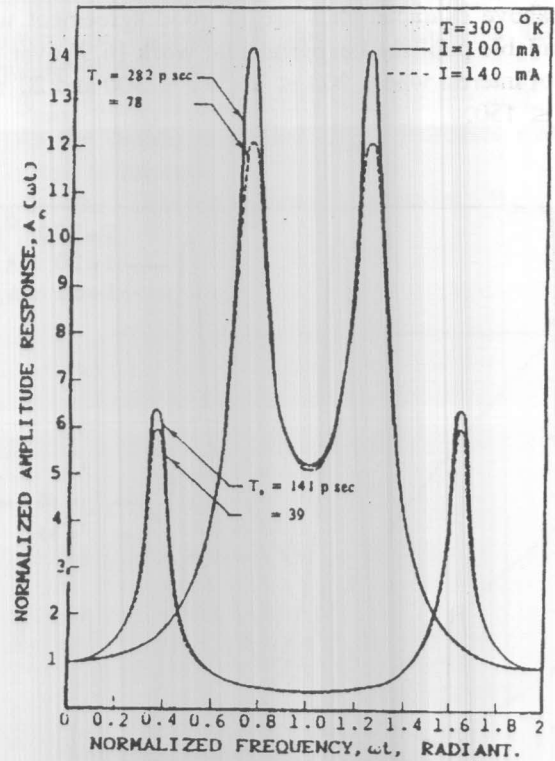


Figure 12. Variation of $A_n(\omega t)$ against the variations of ωt at different injected currents and different sampling intervals.

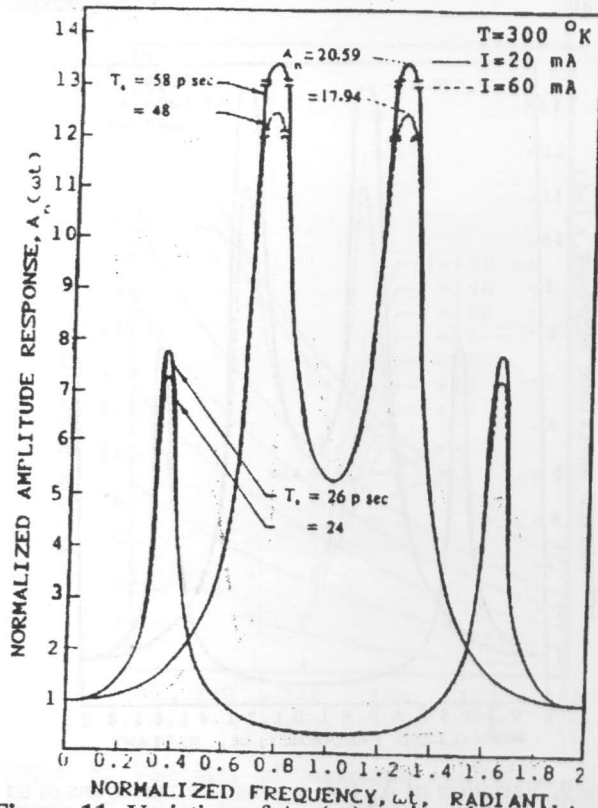


Figure 11. Variation of $A_n(\omega t)$ against the variations of ωt at different injected currents and different sampling intervals.

IV CONCLUSIONS

A small signal thermal dependent model is built to calculate the digital characteristics of InGaAsP laser device under the major affecting parameters, namely the active layer temperature and the injected current. Three relevant items of major interest are studied to account for the thermal digital modulation of the optical device i) The steady state step response and its ultimate value and the ratio between them ii) The 3-dB of the ratio above iii) The steady state harmonic response.

Under digital processing, the cooling of the optical device increases its bandwidth with a monotonic portrait cast under a simple quadratic form as function of the temperature, injected current and other physical and geometrical parameters. Also, as the injected current increases the device bandwidth increases which is in good agreement with the available published experimental work. The processed calculations clarify that the overall harmonic response increases the temperature increases and as the injected current decreases.

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